

#### **AFRL-ML-WP-TP-2007-534**

# CONTRA-DIRECTIONAL TWO-BEAM COUPLING FOR VARIABLE REAR REFLECTIVITIES IN LinbO3:Fe (PREPRINT)

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**Hardened Materials Branch Survivability and Sensor Materials Division** 

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#### 14. ABSTRACT

- 1. Coating the rear c-surface, we are able to produce a controlled range of rear reflectivity on a photorefractive LiNb03 crystal.
- 2. The contra-directional two-beam coupling does not vary significantly with reduced rear reflection. This agrees with theoretical calculation
- 3. The time response of two beam coupling increases with reduced reflectivity.
- 4. Future work will produce similar work on other types of photorefractive crystals.

#### 15. SUBJECT TERMS

Two Beam Coupling (TBC), Residual Reflection, Photorefractive Crystals

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# Contra-directional two-beam coupling for variable rear reflectivities in LiNbO<sub>3</sub>:Fe



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### **Outline**



- Motivation
- Design and implementation
- Photos and reflectivity data
- Coupling measurements
- Results



### **Motivation**



- Can't afford enough identical samples to explore parameter space on first cut
- "Identical" really means identical
- Same Fe2+/Fe3+ ratio
- Same coating on front and same wedge angle are obviously less important, but can create difficulties in interpretation
- We need to have an experimental handle on the tradeoffs in ultimate transmission (residual reflection), speed of response, and ultimate OD



# Design and implementation of coating

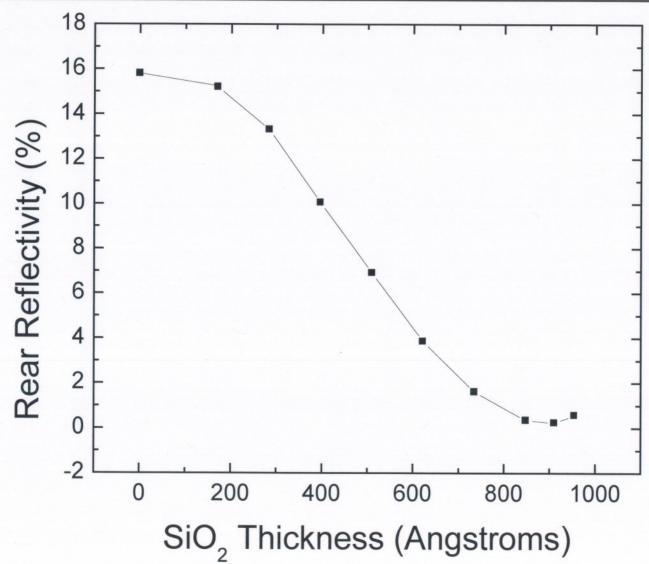


- ➤ We have the ability to RF sputter deposit SiO2
- At 532nm., it is calculated that 911 Angstroms of material will be a quarter wave AR coating. We expect a cosine dependence for reflectivity on thickness as we increase from 0 (uncoated R=15.7%) to 911 A.
- We first put an AR coat on the front (-c) surface
- On the back surface (+c where the arrow points in the picture), we used masks to sequentially deposit 8 different thicknesses (5 min/deposition, last = 7.5min)
- ➤ The masks rested on a 5+mm thick Al plate with a hole cut for the sample to rest on the sputter deposition table
- Witness samples (Si wafer chips) showed a deposition ratio of 1.14 for Al/table
- Reflection measurements indicate front AR = 1% R = 1000 A



## Reflectivity vs. SiO<sub>2</sub> Thickness







# SiO<sub>2</sub> Coating Layer Thickness

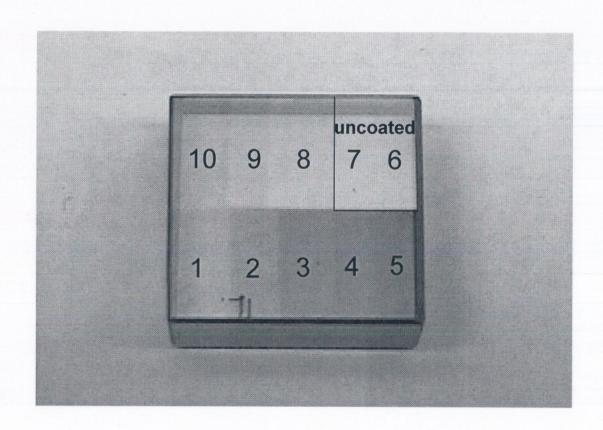


Catis	397	284	171	Uncoated	
	510	622	735	848	955



## **Coated crystal**

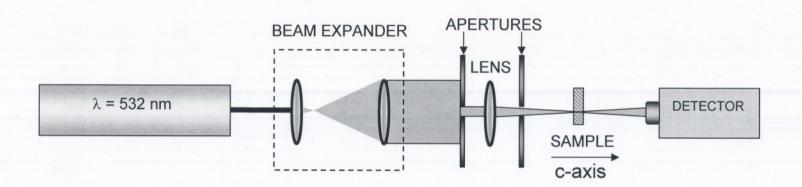






### **TBC Efficiency Measurement**



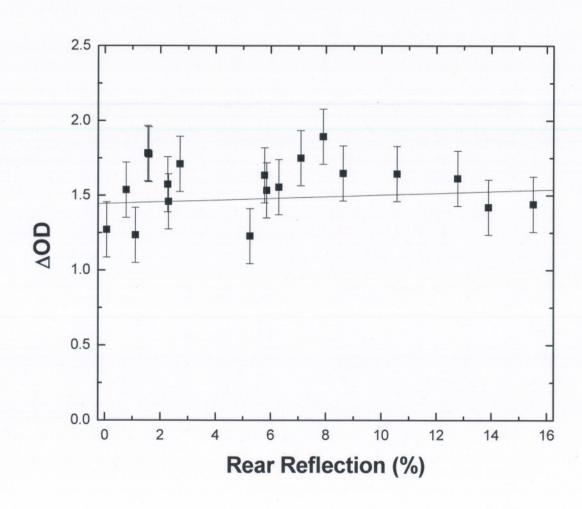


- > TBC efficiency is measured as the change in optical density.
- Optical density = -log(Power<sub>out</sub> / Power<sub>in</sub>).
- Higher TBC efficiency implies Power<sub>out</sub> is smaller.
  - Error sources:
    - Mask placement by hand
    - Material deposition under the mask, giving a gradient
    - Photovoltaic noise changes the steady state transmission
    - Etalon effect may have added error to the transmission (?)



# **∆OD** vs. Rear Reflectivity

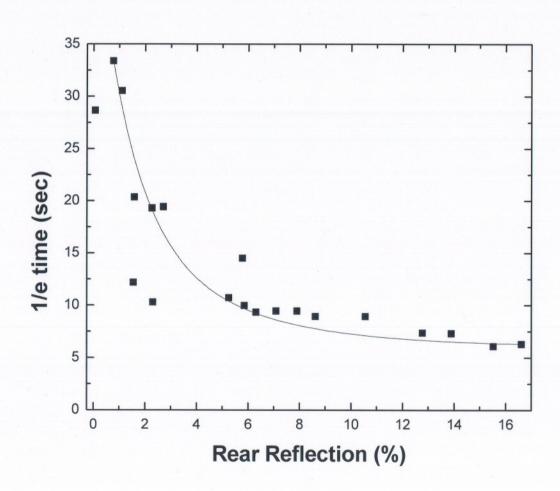






### Decay time vs. rear reflectivity

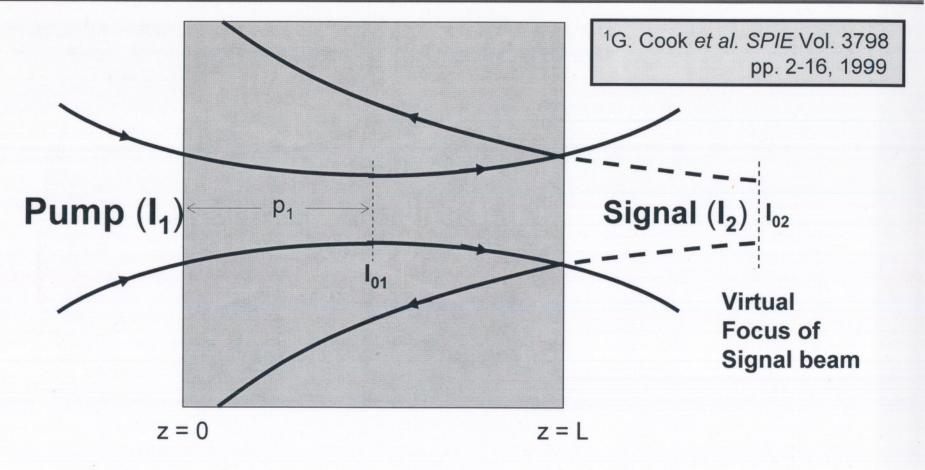






### Theoretical Model<sup>1</sup>





$$I_{01} = \frac{(1 - R_f)P_{inc}}{\pi r_0^2} \quad ; \quad I_1(z) = \frac{I_{01}}{1 + \left[\frac{(z - p_1)^2}{z_R^2}\right]} \quad ; \quad I_2(z) = \frac{I_{02}}{1 + \left[\frac{[z - (2L - p_1)]^2}{z_R^2}\right]}$$



## **Coupled Equations at Steady State**



$$\frac{dI_1}{dz} = \frac{-2(z - p_1)I_1}{z_R^2 + (z - p_1)^2} - \alpha I_1 - \frac{\Gamma I_1 I_2}{I_1 + I_2 + I_d}$$

$$\frac{dI_2}{dz} = \frac{-2(z - (2L - p_1))I_2}{z_R^2 + (z - (2L - p_1))^2} + \alpha I_2 - \frac{\Gamma I_1 I_2}{I_1 + I_2 + I_d}$$

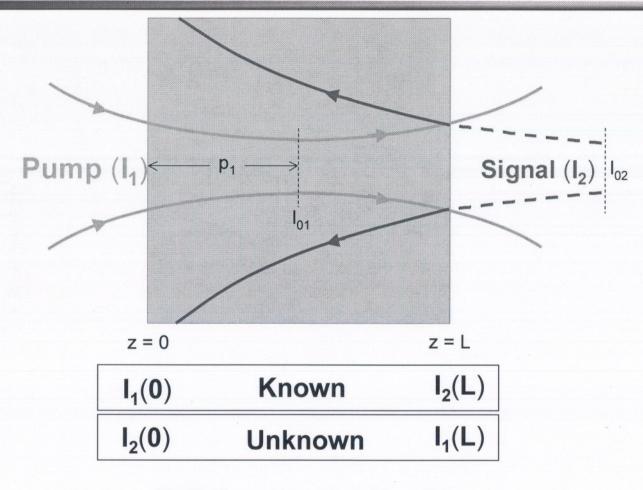
- First term accounts for the diffraction of the beams.
- Second term accounts for the linear absorption, where  $\alpha$  is the linear absorption coefficient.
- Last term represents the two beam coupling between the two beams.  $\Gamma$  is the coupling coefficient between the two beams,  $\mathbf{I_d}$  is the thermal equivalent intensity<sup>1</sup>, representative of the effect of the dark conductivity in the crystal. (Dark conductivity erases grating)
- These equations are solved numerically using a shoot and solve method.

<sup>1</sup>G. Cook et al. SPIE Vol. 3798 pp. 2-16, 1999



## **Calculating Two Beam Coupling**





TBC ~  $I_1(L)/I_1(0)$ 



### **Summary**



- Coating the rear c-surface, we are able to produce a controlled range of rear reflectivity on a photorefractive LiNbO<sub>3</sub> crystal.
- 2. The contra-directional two-beam coupling does not vary significantly with reduced rear reflection. This agrees with theoretical calculation
- 3. The time response of two beam coupling increases with reduced reflectivity.
- 4. Future work will produce similar work on other types of photorefractive crystals.